

Introduction

Electron beam with high bunch charge and high repetition rate is required for electron cooling of ion beam to achieve the required high luminosity of proposed electron-ion colliders. Improved design of the -300 kV DC high voltage photogun at Jefferson Lab was incorporated toward overcoming the beam loss and space charge current limitation as experienced in the original design. To reach the bunch charge goal of \sim few nC within 75 ps bunches, the existing DC high voltage photogun electrodes and anode-cathode gap were modified to increase the longitudinal electric field (E_z) at the photocathode. The anode-cathode gap was reduced to increase the E_{τ} at the photocathode and the anode aperture was spatially shifted with respect to the beamline longitudinal axis to minimize the beam deflection introduced by the geometric asymmetry of the inverted insulator photogun. The electrostatic design and the beam dynamics simulations were performed to determine the required modification. Beam based measurement from the modified gun confirmed the reduction of the beam deflection which is presented in this contribution.

Design Strategy and Experimental

- \Box The accelerating electric field (E_z) at the photocathode sets the limit on the maximum charge density extractable from the photocathode
 - Increase E_{z} at the cathode by:
 - ✓ Removing the 25° Pierce geometry
 - \rightarrow flat cathode and flat anode front
 - \checkmark Reducing the anode-cathode gap to 5 cm from 9 cm
- □ Inverted insulator and triple point junction shied, asymmetric NEG pumps altogether introduce asymmetric electric field in between the anode-cathode gap which results in deflecting the beam vertically at the exit of the anode, difficulty in beam steering, and ultimately beam losses
 - \succ To correct the beam deflection with minimum changes:
 - \checkmark Y deflection \rightarrow Shift the anode aperture -1.6 mm vertically \checkmark X deflection \rightarrow Replace existing NEGs with thinner strips
- □ To prevent high voltage insulator breakdown (i.e., arcing) and linearize the potential across the insulator
 - Design triple junction shield
- □ Reliable operation at -300 kV high voltage with high quality beam and 10⁻¹² Torr scale vacuum without field emission and high voltage breakdown. Minimizing field emission for longer photocathode lifetime
 - \checkmark Optimize electrode shape (radius of curvature), size, and anodecathode gap to have electric field \leq -10 MV/m at -350 kV everywhere inside the chamber
 - Polished electrodes, High voltage conditioning
- Used CST Studio Suite's electromagnetic field solver for electrostatic design □ Used the particle tracking code GPT to simulate beam transport from the
- photocathode Beam deflection minimization is verified by comparing beam steering required for original and new photogun in a beam line of the Gun Test Stand:



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IMPROVED ELECTROSTATIC DESIGN OF THE JEFFERSON LAB 300 KV DC PHOTOGUN AND THE MINIMIZATION OF BEAM DEFLECTION

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